



Atty. Dkt. No. 039153-0371 (F0812)

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Lukanc et al.
Title: METHOD OF ENHANCING
GATE PATTERNING
PROPERTIES WITH
REFLECTIVE HARD MASK
Appl. No.: 09/845,654
Filing Date: 04/30/2001
Examiner: Maldonado, Julio J.
Art Unit: 2823

CERTIFICATE OF MAILING I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on the date below. <u>Sandra A. Murphy</u> (Printed Name) <u>Sandra A. Murphy</u> (Signature) <u>November 25, 2002</u> (Date of Deposit)

AMENDMENT

Commissioner for Patents
Box NON-FEE AMENDMENT
Washington, D.C. 20231

Sir:

This communication is responsive to the Office Action dated September 19, 2002, concerning the above-referenced patent application.

Please amend the application as follows:

In the Claims:

In accordance with 37 CFR § 1.121, please substitute for original claims 1, 7, and 14, the following rewritten versions of the same claims, as amended. The changes are shown explicitly in the attached "Marked Up Version Showing Changes Made."

Please amend the following claims.

1. (Once Amended) A method of fabricating an integrated circuit, the method comprising:

depositing a reflective metal material layer over a layer of polysilicon;

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